

**We are so pleased to announce the recipients of AM-FPD '11 Paper Award.
They will be presented the award in the Opening Session of AM-FPD '12.**

AM-FPD '11 Best Paper Award

Hidehito Kitakado, Sharp

(3-2) Channel Shortening Phenomenon Due to Redox Reaction in a Lateral Direction on In-Ga-Zn-O Thin-Film Transistors

AM-FPD '11 Poster Award

Shin-Ichiro Kuroki, Tohoku Univ.

(P-L3) Crystal Growth of Highly Biaxially-Oriented Poly-Si Thin Films by W-Line Beam Continuous-Wave Laser Lateral Crystallization

AM-FPD '11 Student Paper Award

Jean de Dieu Mugiraneza, Univ. of the Ryukyus

(L-2) Crystallization of Si Thin-Film on Flexible Plastic Substrate by Using Blue Multi-Laser Diode Annealing